Investors Relations

Y2026

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Global Leader in Mask Blank & EUV Nano- technology

Company Name	S&S Tech Corporation
CEO & Chairman	Jeong, SooHong
Founded	February 22nd, 2001
Employees	335 (As of 2026. 01)
Business	Mask Blank for Semiconductor and FPD
Public Listing	KOSDAQ (101490)
Headquarter	Daegu, South Korea
Patents	236 listed (Domestic 110/ International 121)

EUV Center

- Location : Yongin City
- Establish : 2025.10.15
- Land : 8,250 [m^2]
- C/R : 3,630 [m^2]
- Product : **EUV product**

Daegu Headquarter

- Location : Daegu City
- Land : 13,200 [m^2]
- C/R : 5,450 [m^2]
- Product : Optical Mask Blank & **EUV product**

Global Leader in Mask Blank & EUV Nano- technology

S&S TECH

2001 2009

1. Market Entry

- Established S&S Tech
- Korea's first development and production of IC/FPD Mask Blank
- 2005 Newtech Award from the President of Korea
- 2008 Appointed as Korea's Top 10 New Tech
- USD $20M Export

2009 2016

2. Growth Period

- High-End Market Entry
- 2009 KOSDAQ IPO
- 2014 World Class 300
- 2016 2nd Production Site Expansion in Daegu

Global Leader in Mask Blank & EUV Nano- technology

S&S TECH

2017 2025

3. Expansion Period

- 2017 EUV Pellicle Development
- 'High-Tech Company' Certification
- 2020 EUV Mask Blank Development
- 2025 EUV Center in Yongin Established
  (Mass Production Readiness)
- USD $70M Export

2025 ~

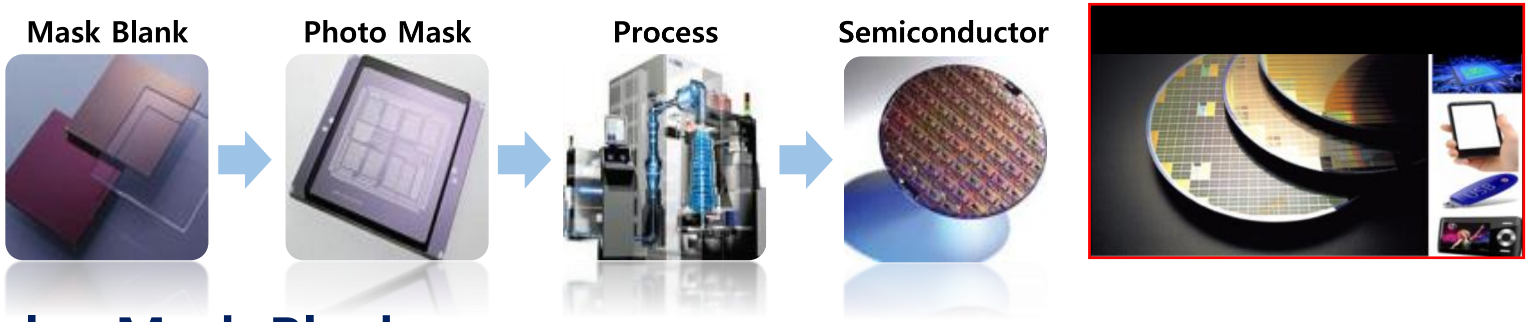
4. Upcoming Items

- EUV Pellicle Business
- EUV Mask Blank full development & Business

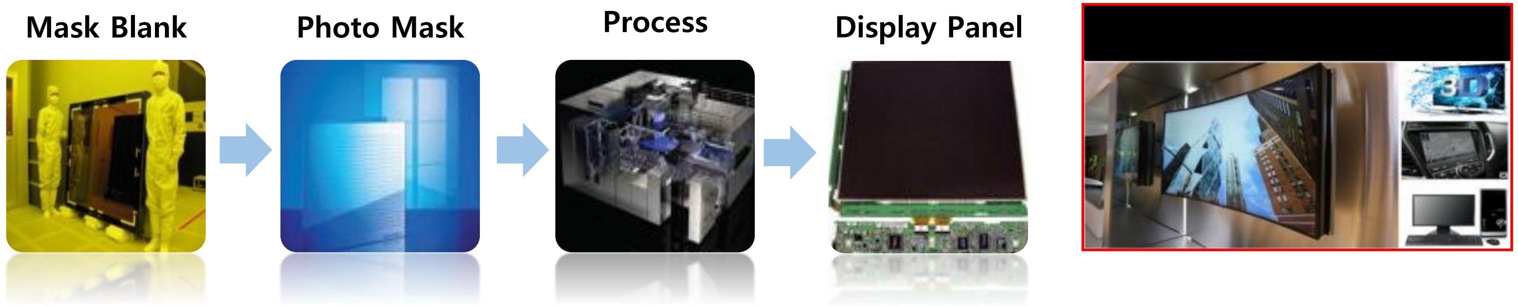
First Locally Developed – Mask Blank

▪ Mask Blank is the main raw material for photomasks/reticle (without patterns) and can be applied to semiconductors (Memory and Non-memory) and display (TFT-LCD, OLED, LED)

Semiconductor Mask Blank



Display Mask Blank



Key Figures

S&S TECH

Financial	**+25% YoY** Revenue 5Y CAGR 2021~2025 (Consolidated)	**+41% YoY** Operating Profit 5Y CAGR 2021~2025 (Consolidated)	**243B** Revenue Y2025 Consolidated	**50B** Operating Profit Y2025 Consolidated
Ownership	**236** Patents Listed Domestic & International	**335** Employees As of 2026. 01	**Investment, Bio Lab** S&S Investment S&S Lab	
Customers	**About 70%** Export rate by total revenue	**About 30+** # of Customers Globally		

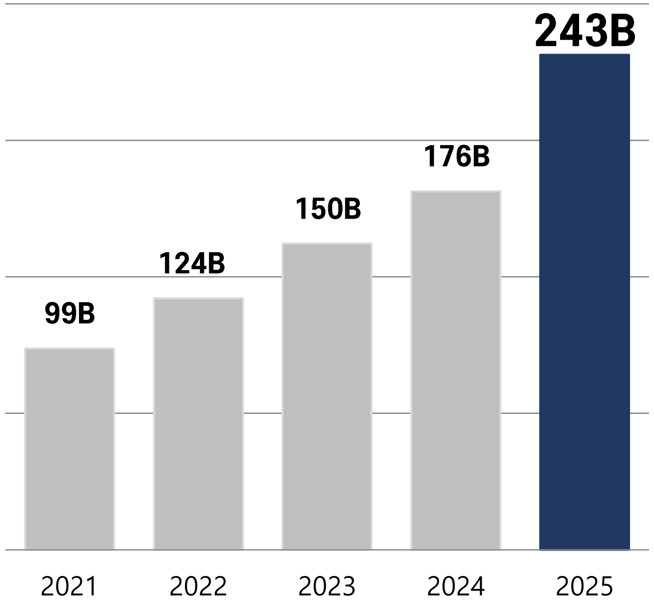
Units : KRW

2025 Financial Summary (Consolidated YoY)

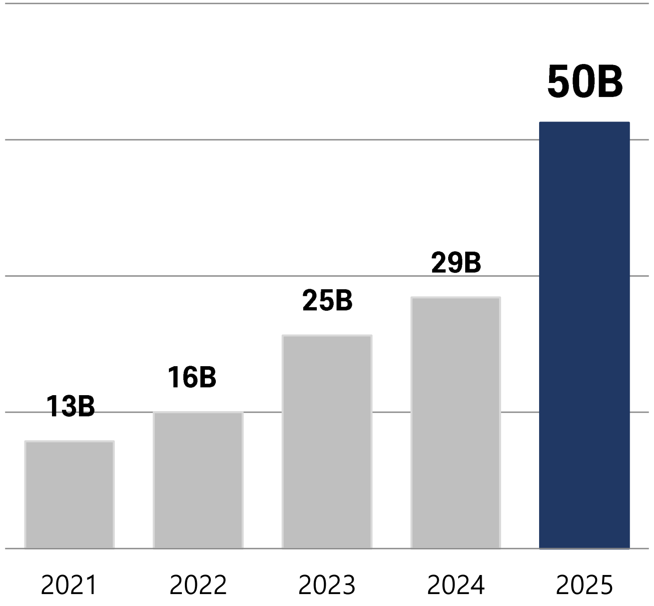
S&S TECH

- In 2025, sales reached 243B KRW with an operating profit of 50B KRW, maintaining an annual growth rate of around 25% over the past 5 years.
- With the growth of the next- generation semiconductor and display markets, annual revenue continues to rise.

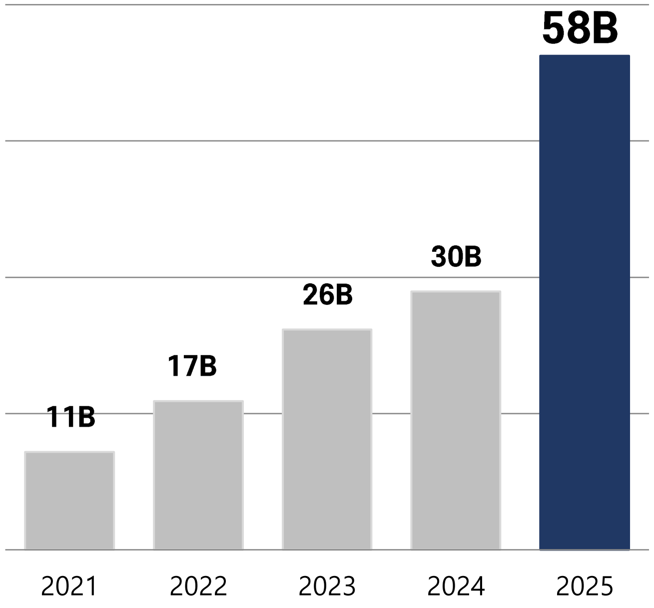
Units : KRW



Sales



Operating Profit



Net Profit

Key Investment Points

S&S TECH

01. Steady Growth in Sales

✓ Maintaining a CAGR of +25% in sales and +41% in OP over the past 5 years.

03. Growth in Semiconductor & FPD market

✓ Securing market share and customers in the growing semiconductor and display sectors

02. Future Oriented Business Structure

✓Investment in facilities and equipment tools for the next generation semiconductor

✓Established an EUV Center in Yongin for HVM

04. Partnership with customers based on credibility

✓Leveraging existing connections and networking expertise to target a broader and diverse customer base

EUV R&D Roadmap

S&S TECH

- S&S Tech has been investing in EUV Products since 2017, establishing a commercialization structure through a top–tier R&D system.

EUV Kick Off
2017~2020

- EUV Pellicle Development
- EUV Mask Blank Development .

R&D
2020~2022

[Pellicle]
- 400W Pellicle

[Mask Blank]
- Structure Confirmed

R&D
2023~2024

[Pellicle]
- Metal based 400W Pellicle under pre-production
- 600W in development

[Mask Blank]
- Defect control period

Business Development

- Sales- in progress
- Production - Yongin

Global Market Entry
2025~

- Global EUV Market Entry

Thank you.

EOD

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